



High current polarized electron sources development

Luca Cultrera

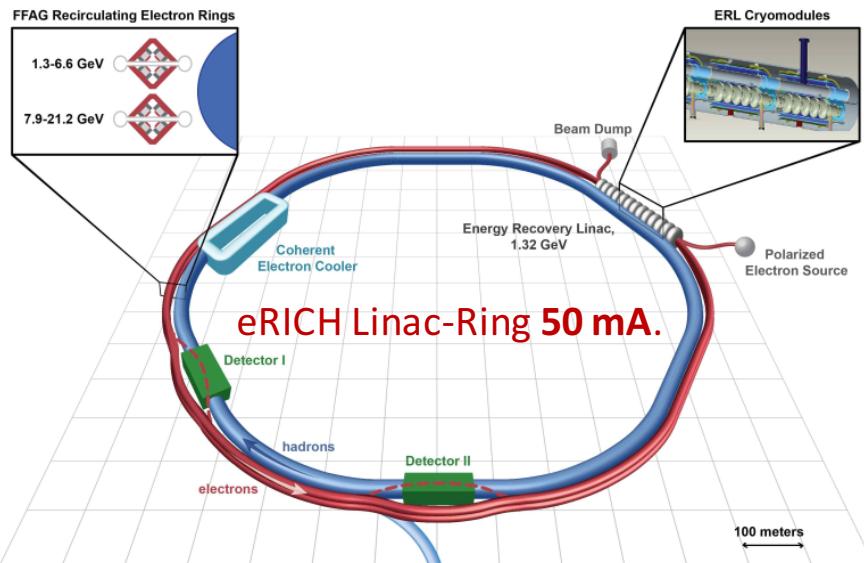


Outline

- Spin polarized photocathode requirements;
- State-of-the-art of GaAs-based photocathodes;
- Photoemission R&D at Cornell University;
- Cs₂Te and Cs₃Sb activated GaAs;
- Outlook and future work;



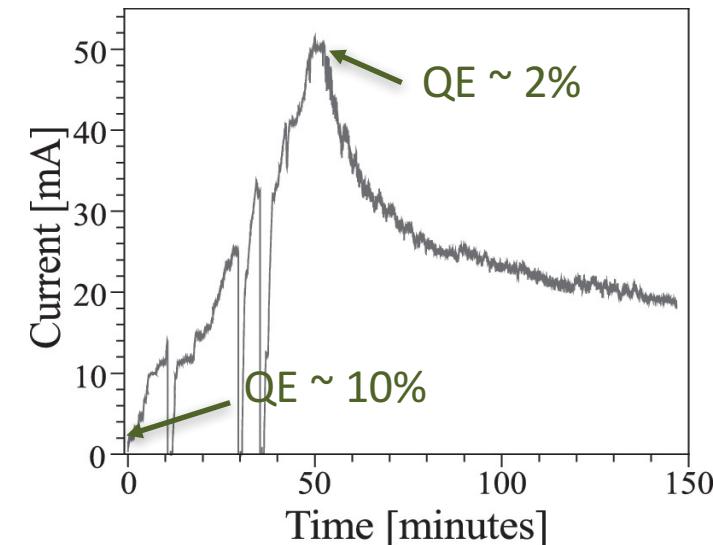
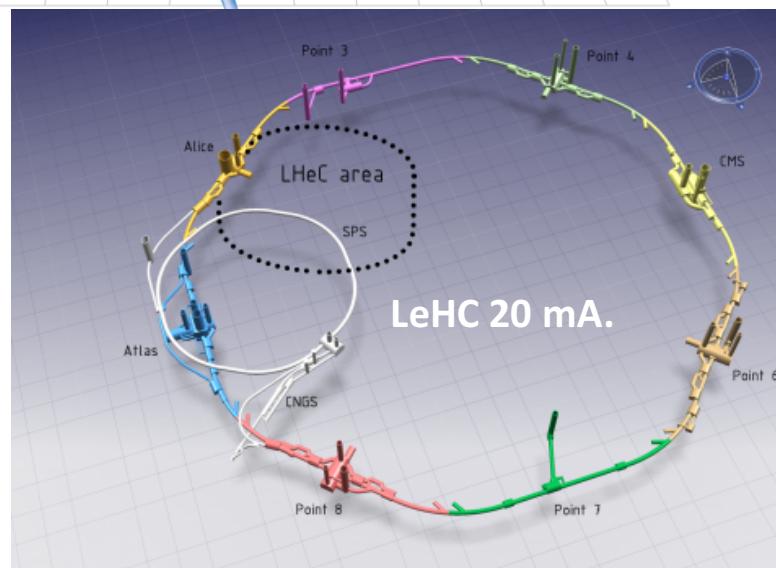
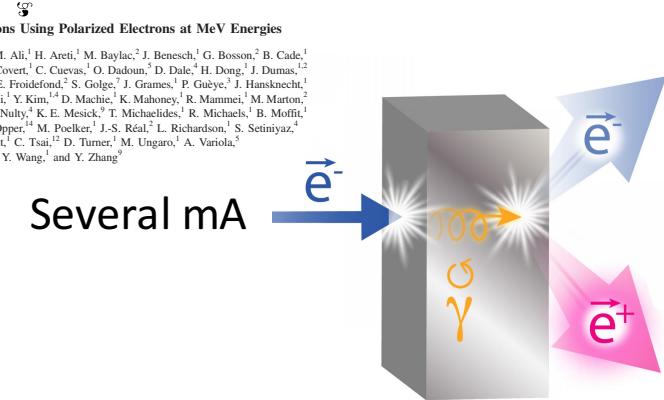
High current and spin polarization



PRL 116, 214801 (2016) PHYSICAL REVIEW LETTERS week ending 27 MAY 2016

Production of Highly Polarized Positrons Using Polarized Electrons at MeV Energies

D. Abbott,¹ P. Adderley,³ A. Adeyemi,³ P. Aguilera,¹ M. Ali,¹ H. Areti,¹ M. Baylac,² J. Benesch,¹ G. Bosson,² B. Cade,¹ A. Camsonne,¹ L. S. Cardman,¹ J. Clark,¹ P. Cole,⁴ S. Covert,¹ C. Cuevas,¹ O. Dadoun,² D. Dale,⁴ H. Dong,¹ J. Dumas,¹² E. Fanchini,⁷ T. Forest,⁴ E. Forman,¹ A. Freyberger,¹ E. Froidefond,⁷ S. Golge,⁷ J. Grames,¹ P. Guéye,³ J. Hansknecht,¹ P. Harrell,¹ J. Hoskins,¹⁰ C. Hyde,² B. Josey,¹³ R. Kazimi,¹ Y. Kim,¹⁴ D. Machie,¹ K. Mahoney,¹ R. Mammei,¹ M. Marton,² J. McCarter,¹¹ M. McCaughan,¹ M. McHugh,¹⁴ D. McNulty,⁴ K. E. Mesick,⁹ T. Michaelides,¹ R. Michaels,¹ B. Moffit,¹ D. Moser,¹ C. Muñoz Camacho,⁶ J.-F. Muraz,² A. Opper,¹⁴ M. Poelker,¹ J.-S. Réal,² L. Richardson,¹ S. Seiniyaz,⁴ E. Voutier,^{2,6,*} Y. Wang,¹ and Y. Zhang⁹

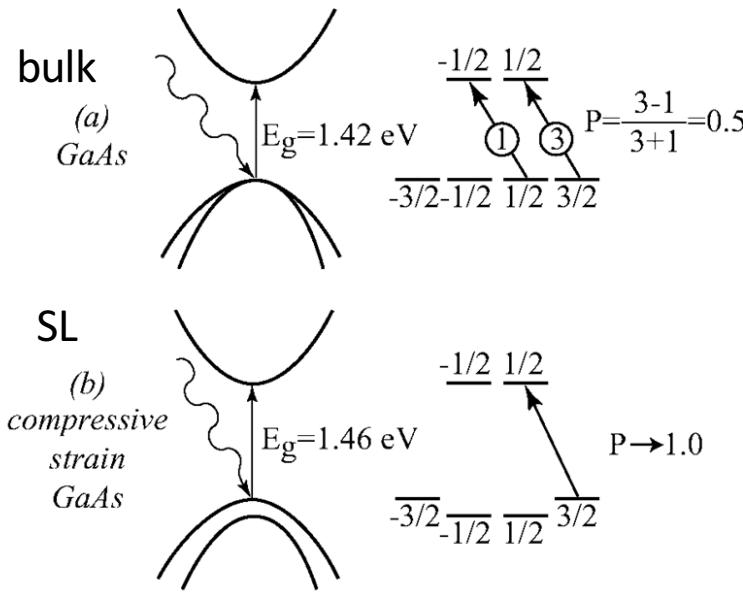


B. Dunham et al, Appl. Phys. Lett. **102**, 034105 (2013)

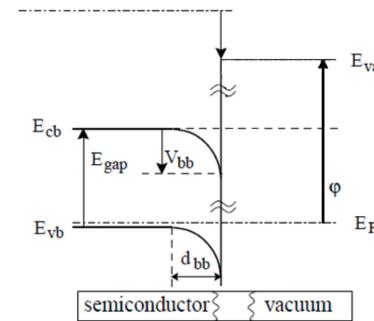


GaAs-based existing photocathodes

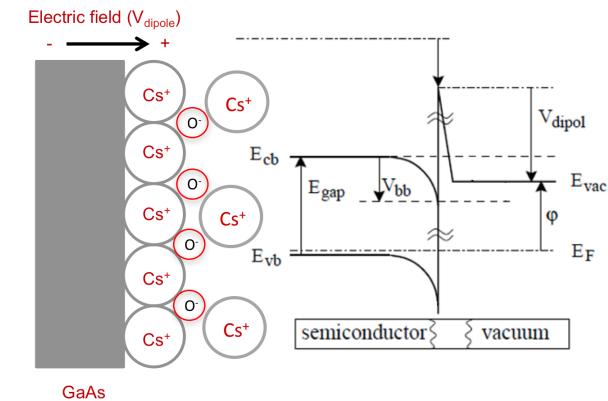
At typical 1% QE the required laser power “on the cathode”
@800 nm to generate 50 mA is about 7 Watts



Before Activation



After Activation
(NEA)



All GaAs based photocathodes requires Cs-O activation to achieve Negative Electron Affinity (NEA) and vacuum levels better than 10^{-11} Torr to survive a few days (without even running the beam)

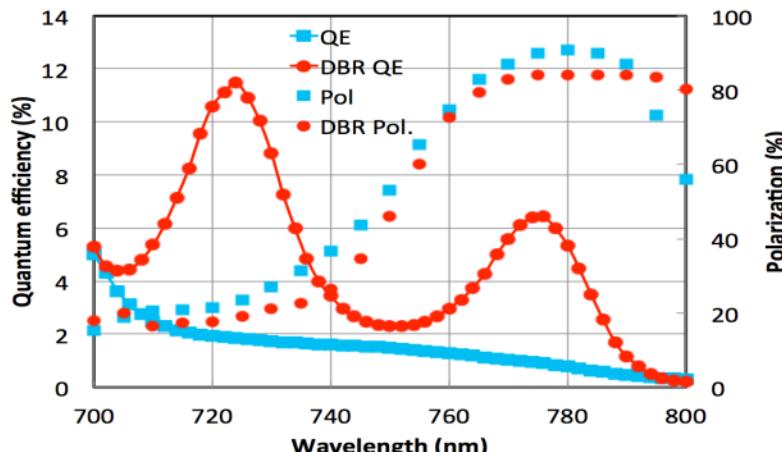


Distributed Bragg Reflector

- Total laser absorption in the SL layer is usually <5%*
- A DBR can be used to reflect the transmitted laser beam back to the SL*

Experimental Results

- non-DBR: QE ~ 0.89%, Pol ~ 92% @ 776 nm:
- DBR: Pol. ~ 84%, QE ~ 6.4%, Enhancement: ~7.2

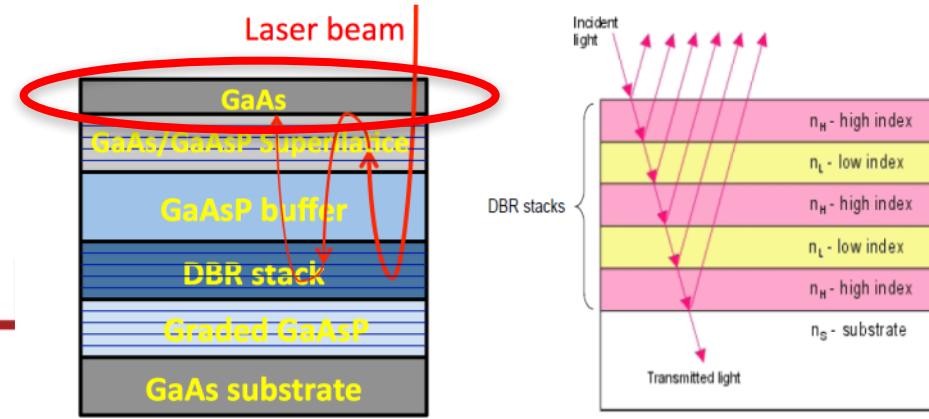


S. ZHANG, P3 Workshop 2016, Newport News, VA

Jefferson Lab

Benefits of DBR

- DBR photocathode : absorpt. in GaAs/GaAsP SL >20%
Less light needed \Rightarrow less heat deposited
- F-P can be formed btw top layer & DBR



S. ZHANG, P3 Workshop 2016, Newport News, VA

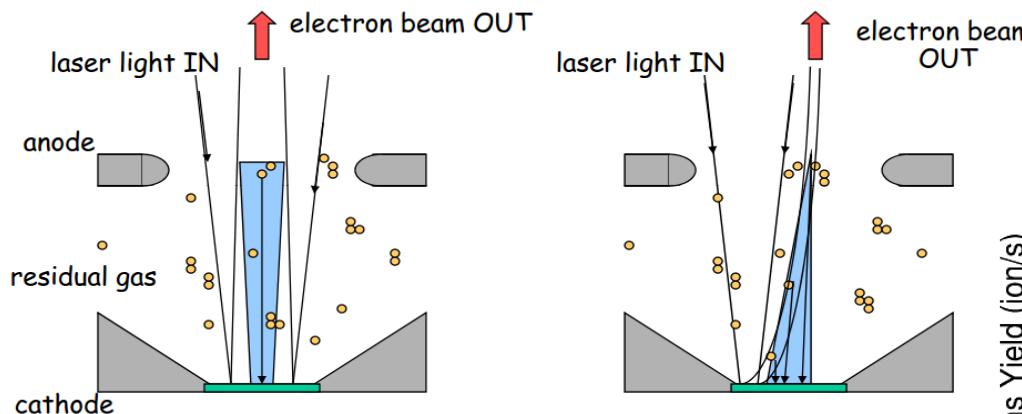
Jefferson Lab

- QE is now a factor 6 larger**
- Potential for higher currents**
- Less laser power, less heat to dissipate**
- Quite complex structure**

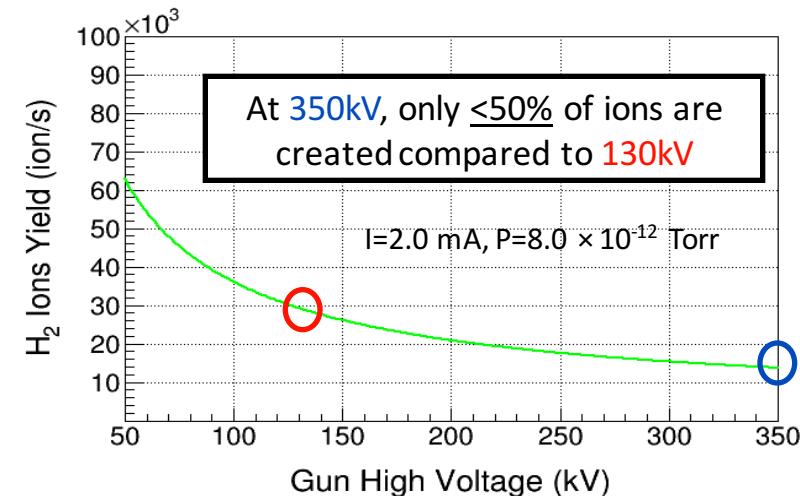
**THE LAST LAYER IS A HIGHLY
P-DOPED BULK GaAs
ACTIVATED WITH Cs-O**

But QE alone is not sufficient

- NEA is achieved and can be maintained only in extreme vacuum
 - XHV require massive pumping to reach 10^{-12} Torr;
- Ions backstreaming is still limiting operating lifetime
 - Clearing electrodes and or biased anode;
 - Higher gun voltages;



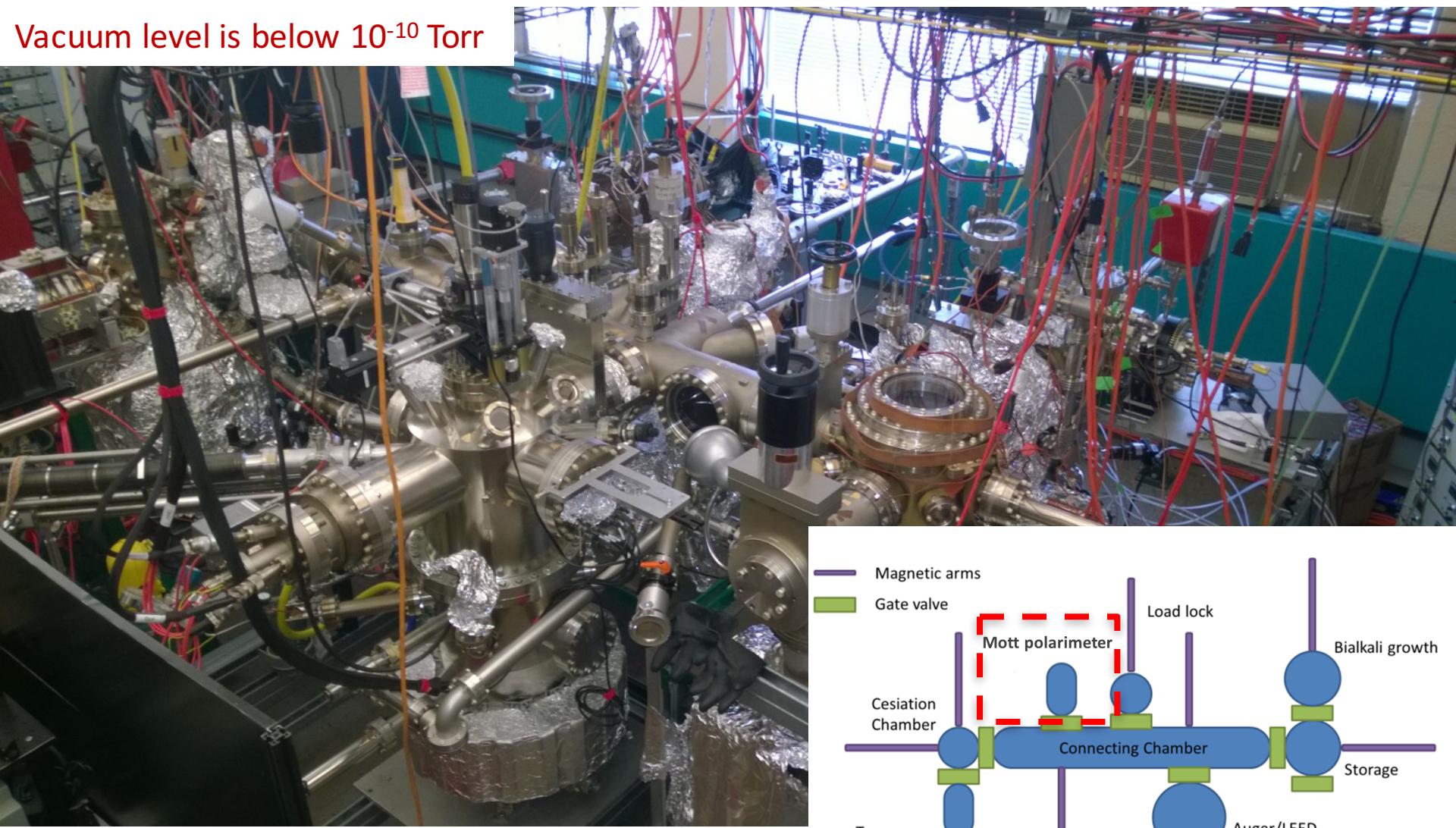
*A single HV breakdown event inside the gun
Can get the vacuum high enough to instantly
“kill” the cathode*





Cornell Photocathode Lab

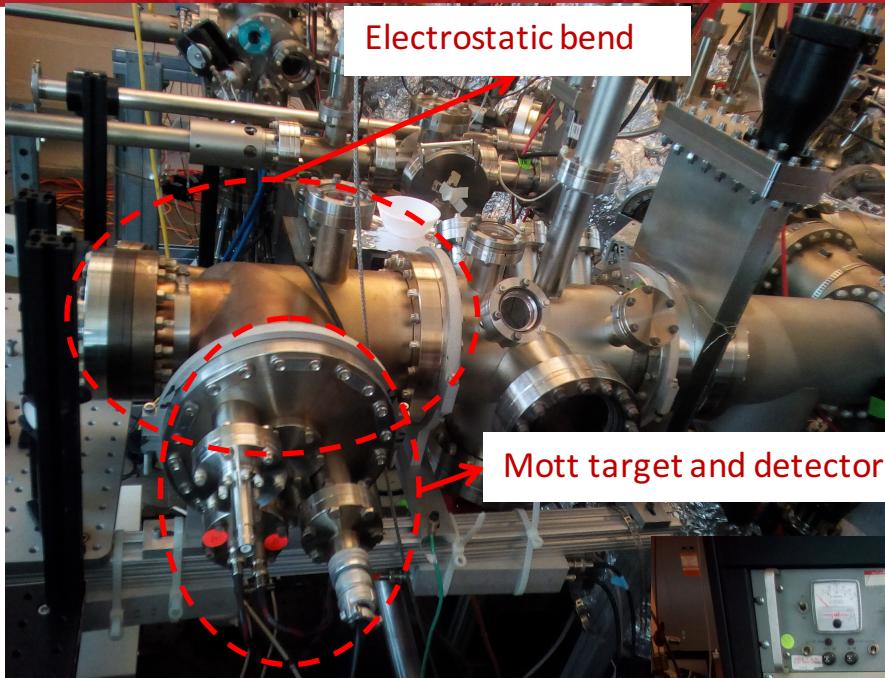
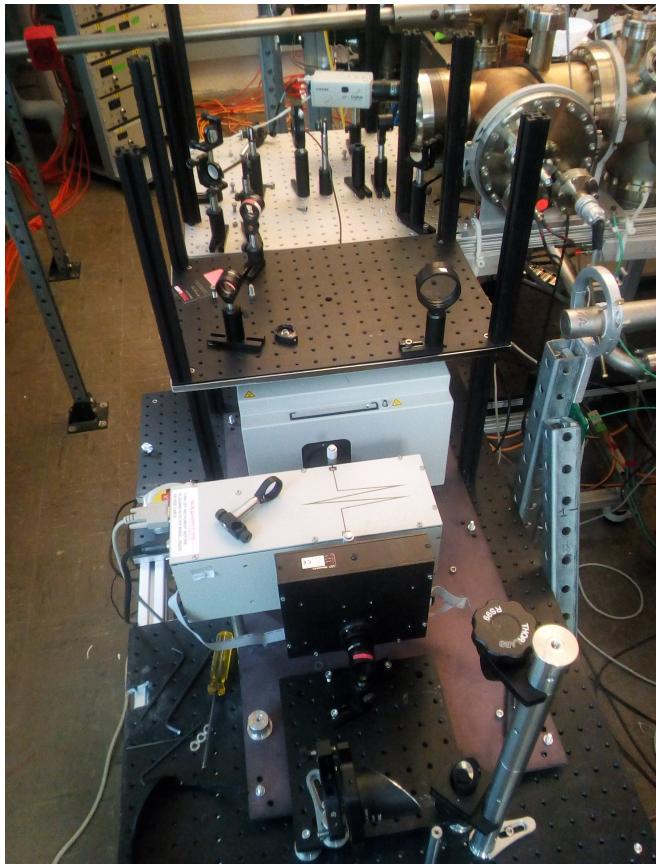
Vacuum level is below 10^{-10} Torr





Mott polarimeter @ CU

Vacuum level is below 10^{-10} Torr



HV gun puck



The retarding field Mott polarimeter has been
refurbished upgraded and fully integrated into the
photocathode lab UHV installation.

15-20 September 2019

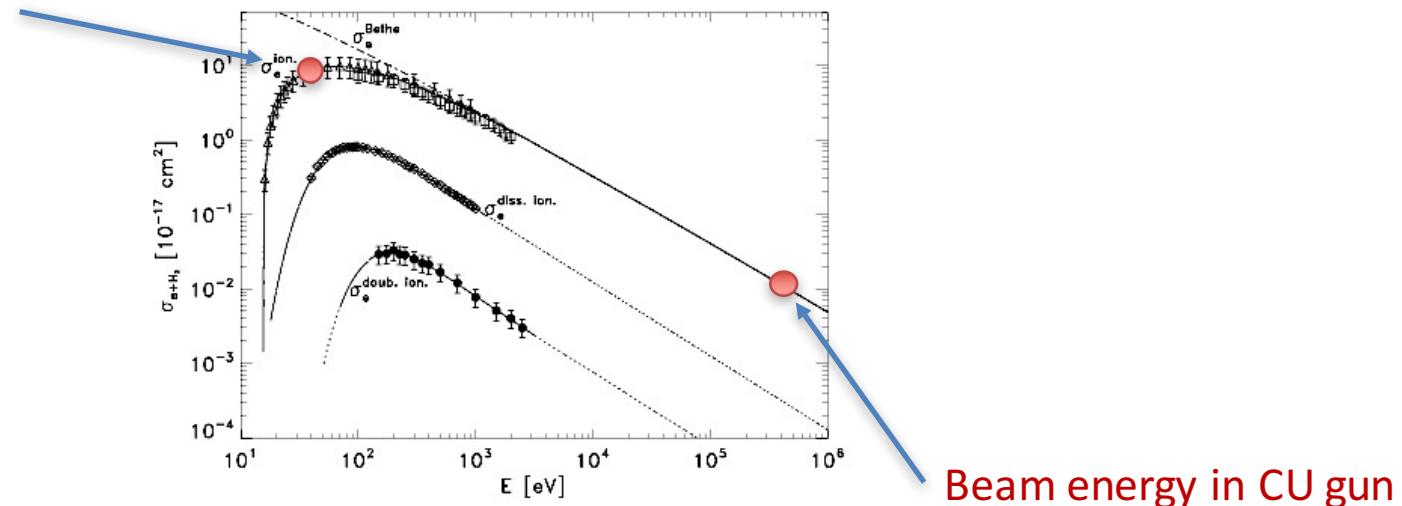
ERL'19 - Berlin

Thanks to M. Poelker and M. Stuzman for helping
in debugging and setting up the polarimeter



- Following measurements are performed:
 - At Very low electric field (bias -36 V);
 - With small cw laser diodes (tens of uW);
 - At vacuum levels of $\sim 5 \times 10^{-11}$ Torr;

Beam energy in our setup is about 36 eV

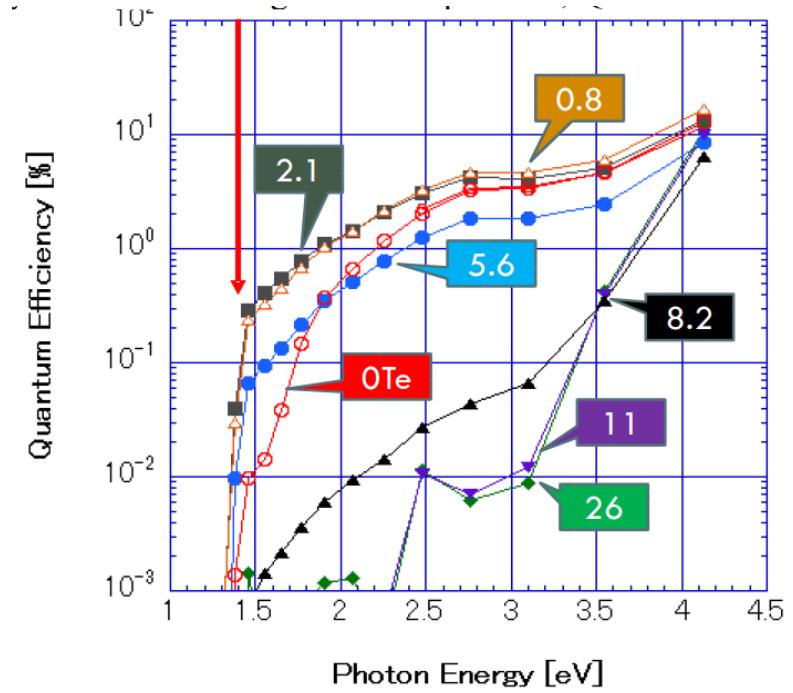
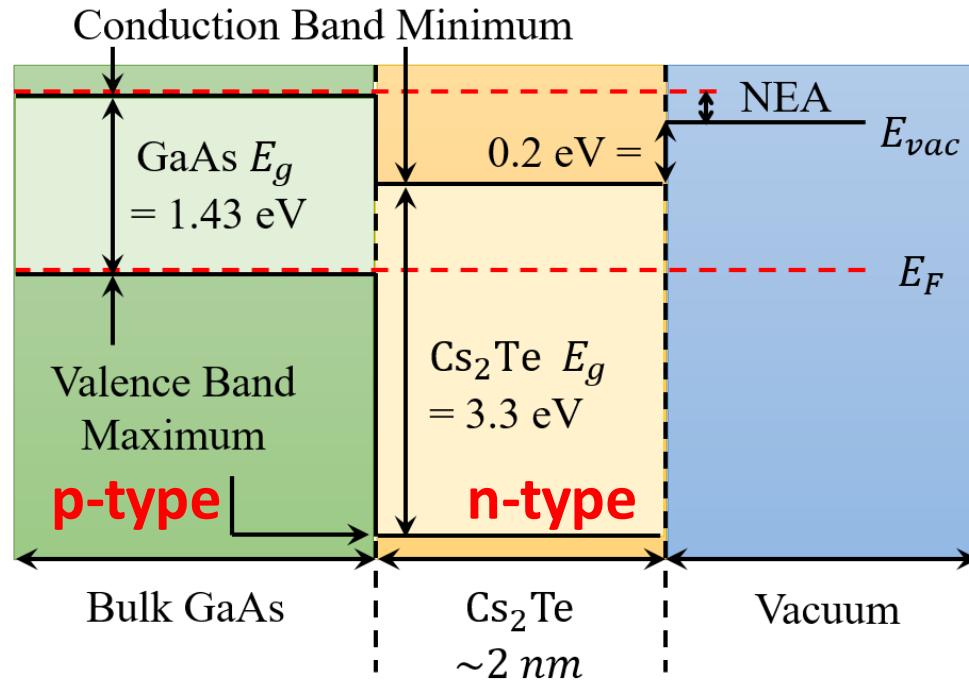


- About 3 order of magnitude larger probability to ionize hydrogen than in a real gun
- Due to low energy electron the **ion back bombardment** damage is likely to affect the very surface of our samples.



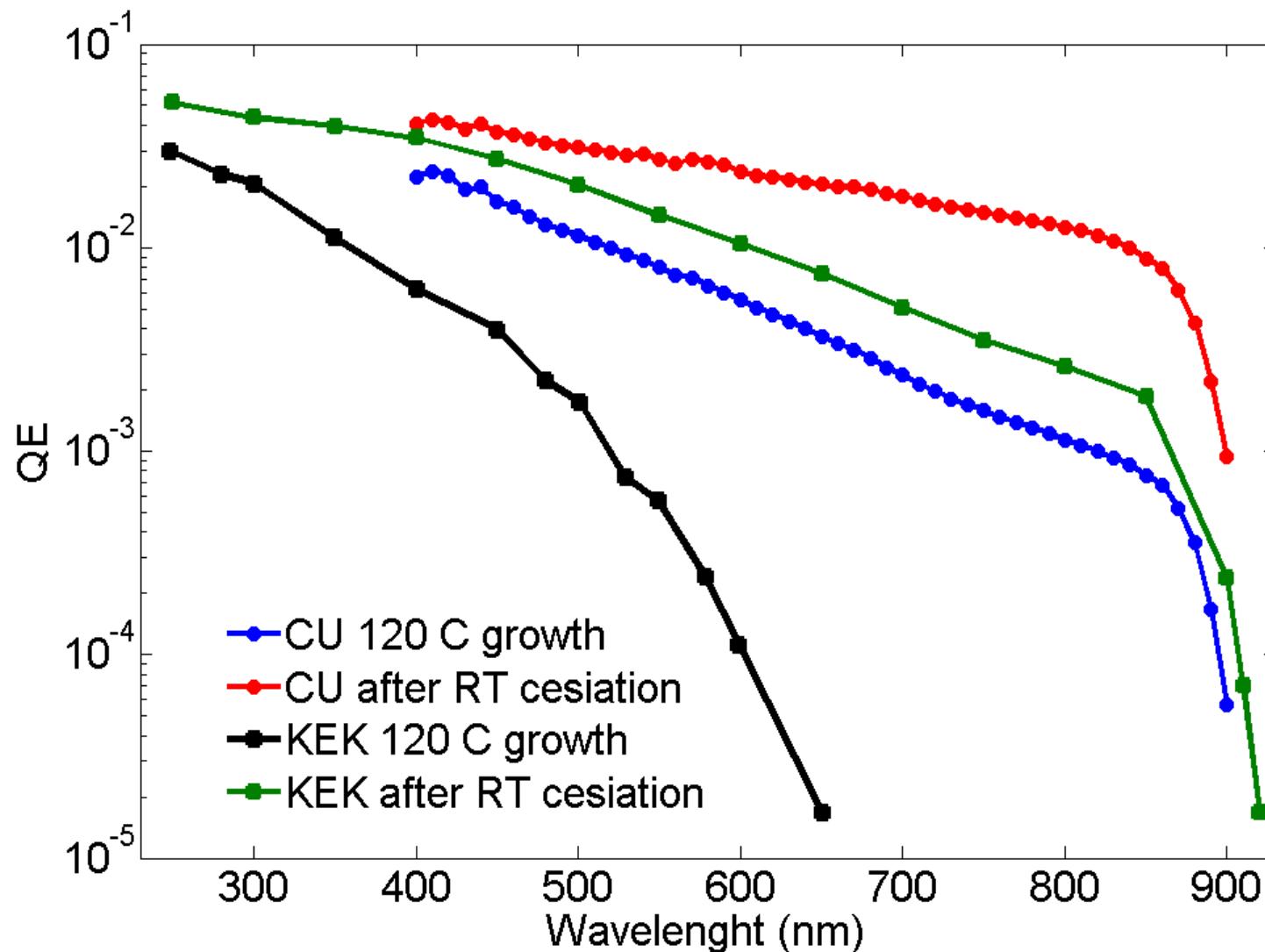
Cs_2Te on GaAs

M. Kuriki, P3 workshop, LBNL, 2014



Will this method yield longer lifetimes?

What happen to the spin polarization?



J. Bae et al., Appl. Phys. Lett. **112** (2018) 154101

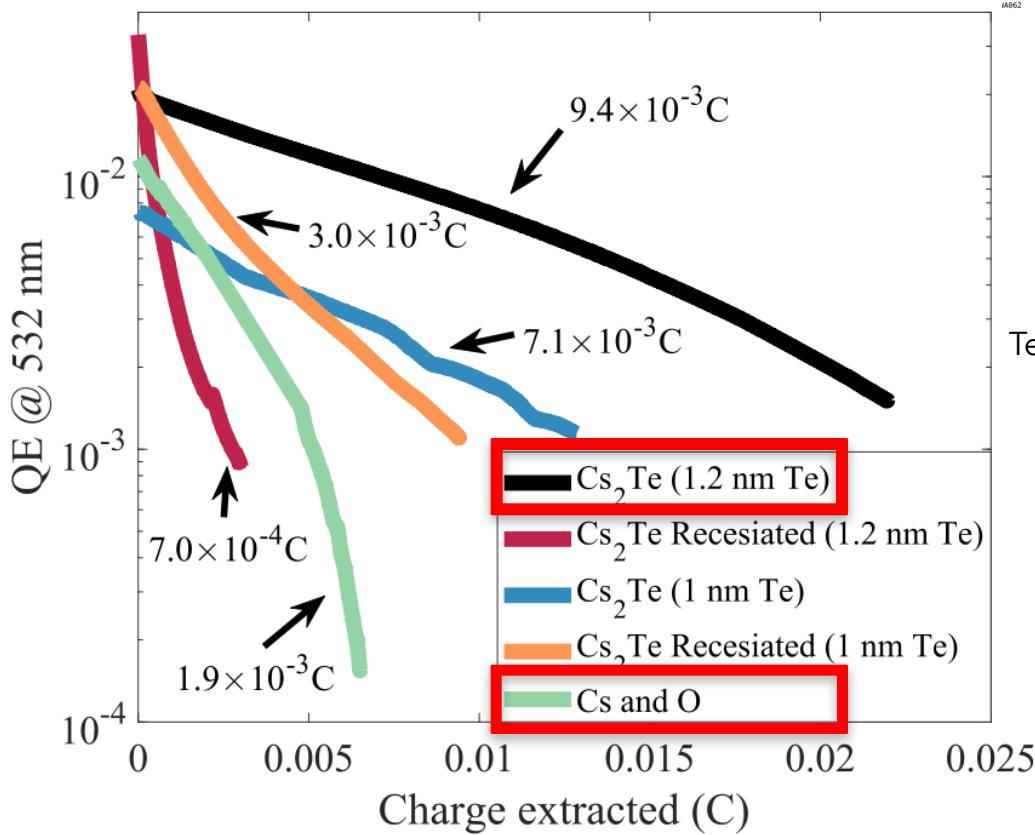


Cs_2Te and CsKTe on GaAs

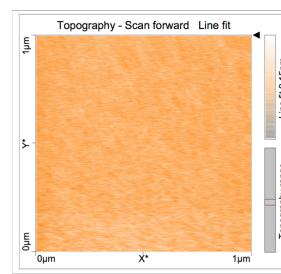
O. Rahman et al., IPAC 2019, TUPTS102

5X LIFETIME!

@532 nm



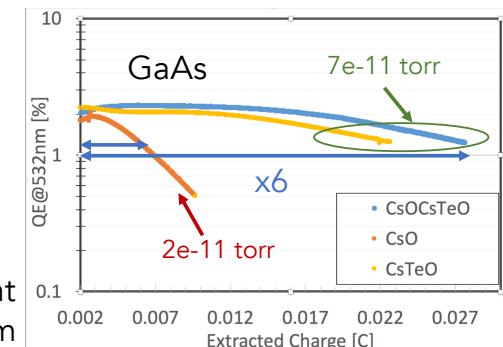
J. Bae et al., Appl. Phys. Lett. **112** (2018) 154101



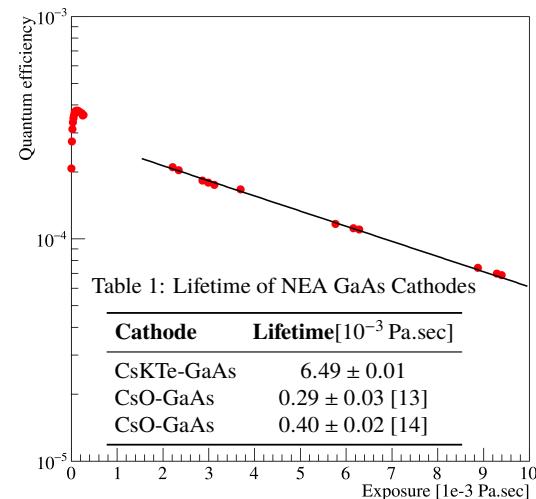
540 °C heat treatment
Roughness: 1.8-3.9 nm



Te source in Saes dispenser



Trying GaAs/GaAsP
and CsI coating now.

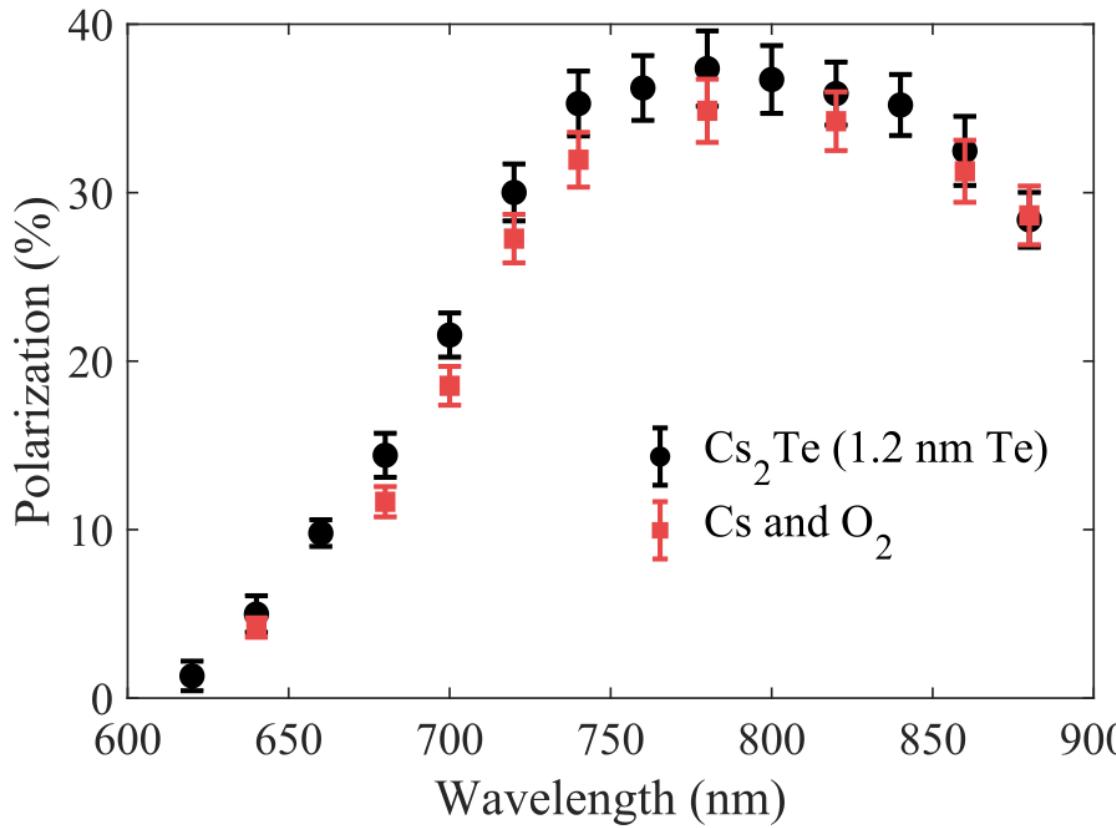


M. Kuriki et al., IPAC 2019, TUPTS026



Electron beam polarization

The same GaAs wafer was activated first with Cs-O and later with Cs_2Te



**Spin polarization is
not affected by the
 Cs_2Te surface layer**

APPLIED PHYSICS LETTERS 112, 154101 (2018)



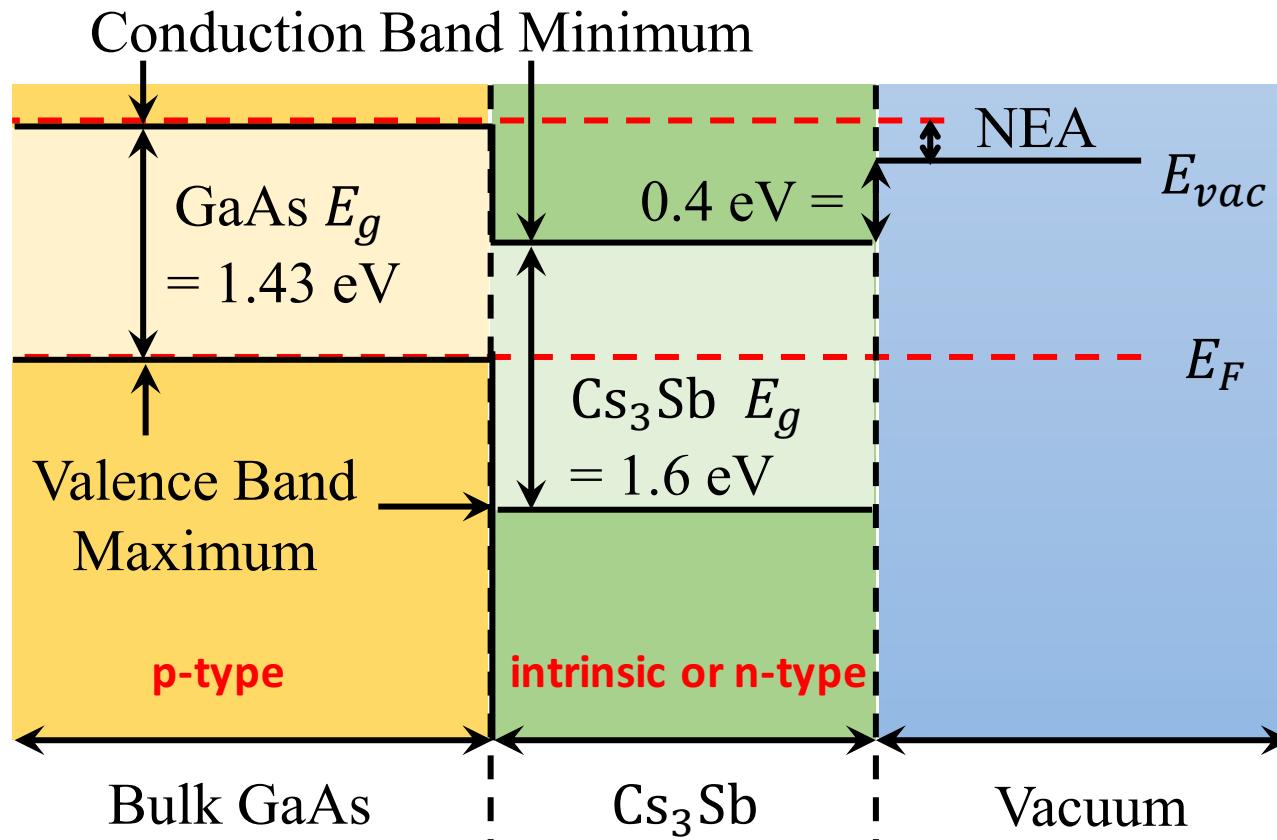
Rugged spin-polarized electron sources based on negative electron affinity
GaAs photocathode with robust Cs_2Te coating

Jai Kwan Bae, Luca Cultrera, Philip DiGiacomo, and Ivan Bazarov
Cornell Laboratory for Accelerator-Based Sciences and Education, Cornell University, Ithaca,
New York 14853, USA

(Received 22 February 2018; accepted 24 March 2018; published online 9 April 2018)



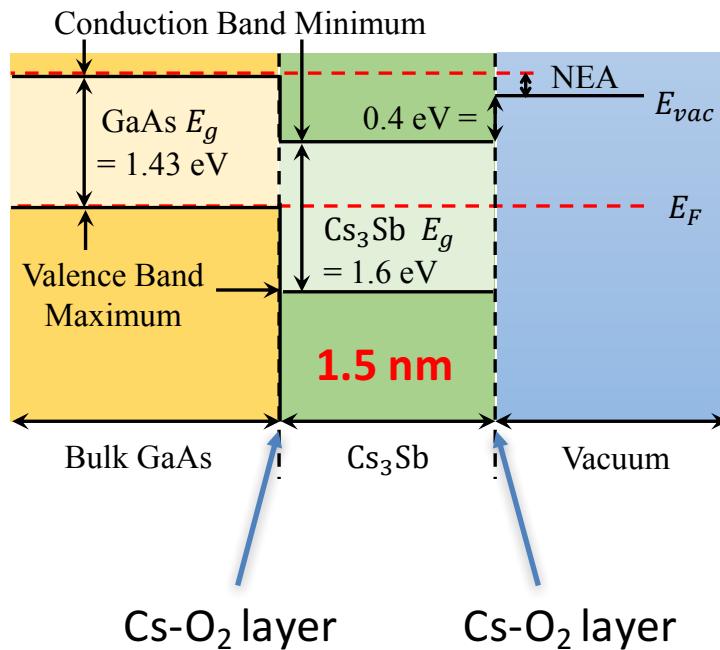
Doping control in alkali based photocathodes materials is difficult



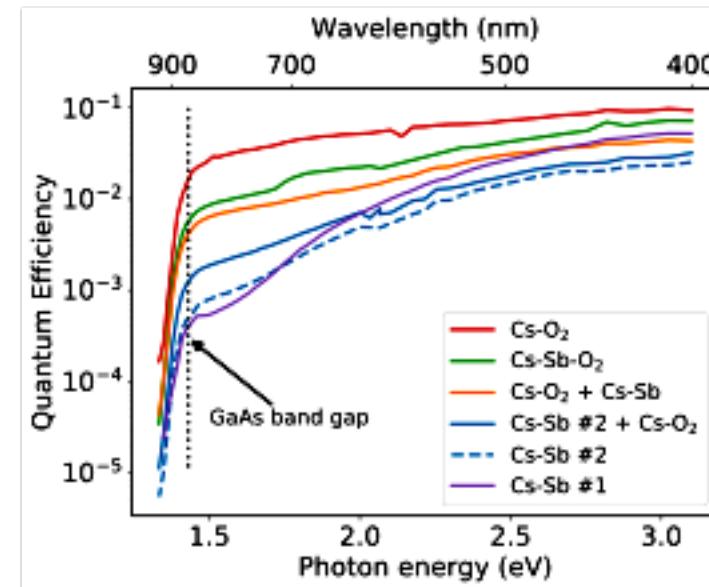
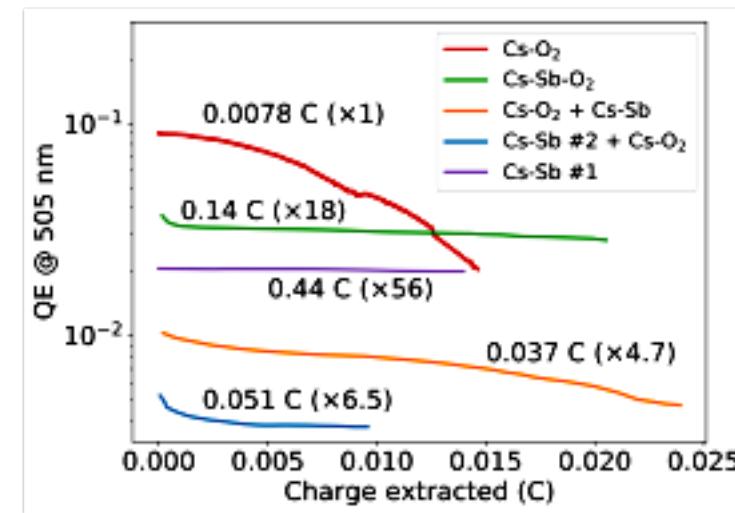
Doping character is controlled by the stoichiometry



Cs_3Sb on GaAs - Methods



J. Bae et al, NAPAC 2019, MOPLH17

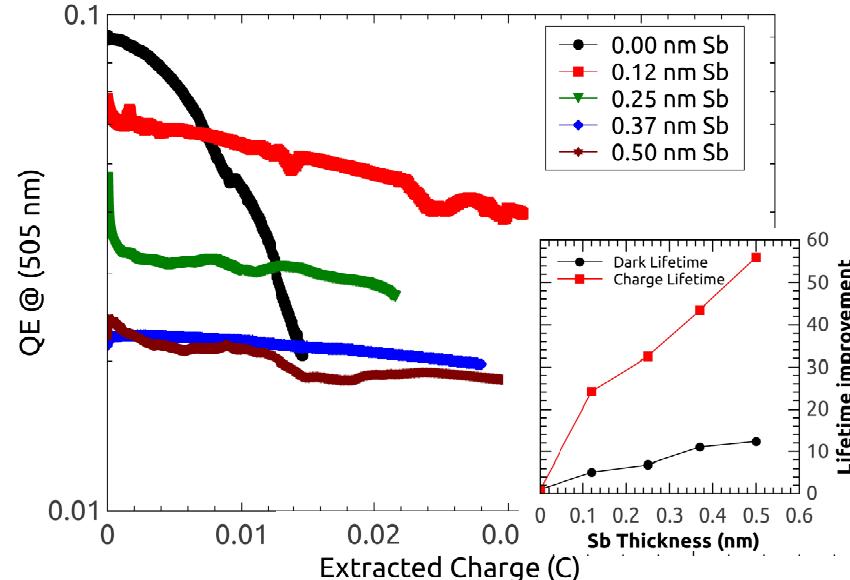
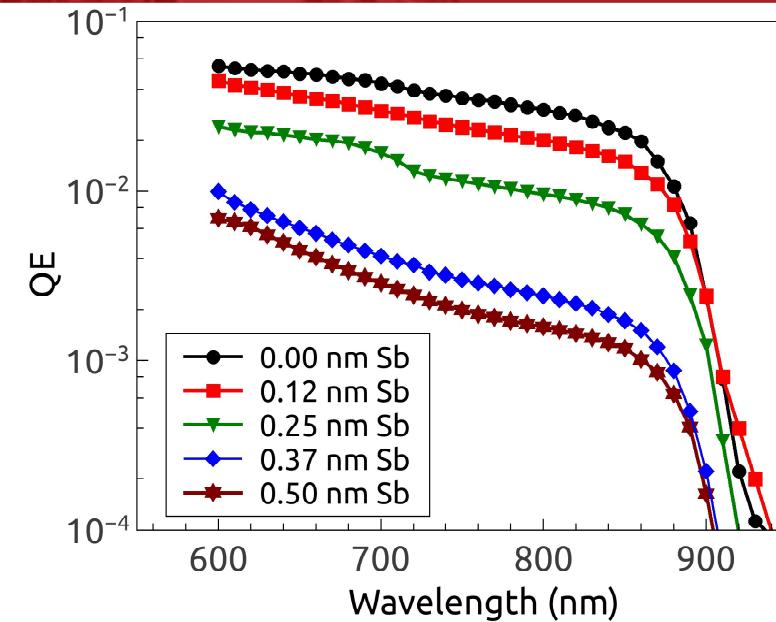
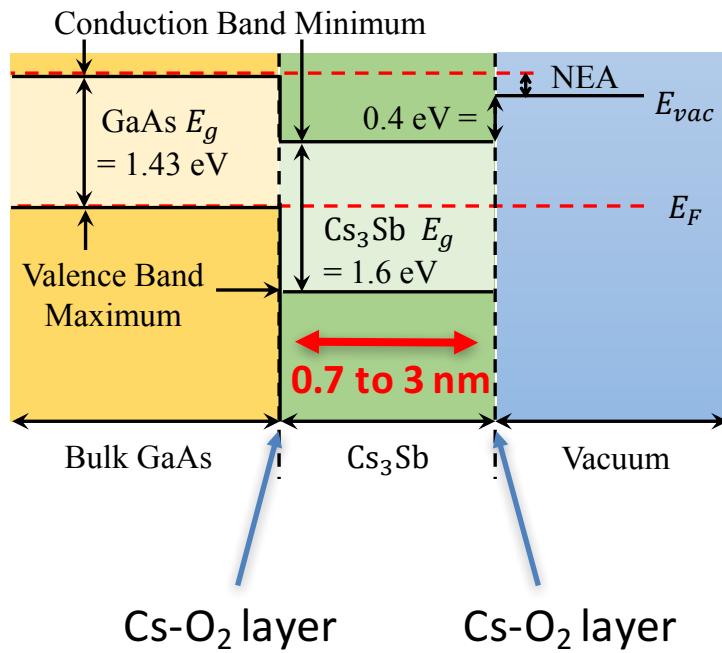


All the methods allowed reaching NEA
co-deposition of Cs-Sb-O_2 allow:

- the longer lifetimes (x20)
- and the higher QE (1/2 of Cs-O_2)



Cs_3Sb on GaAs - Thickness



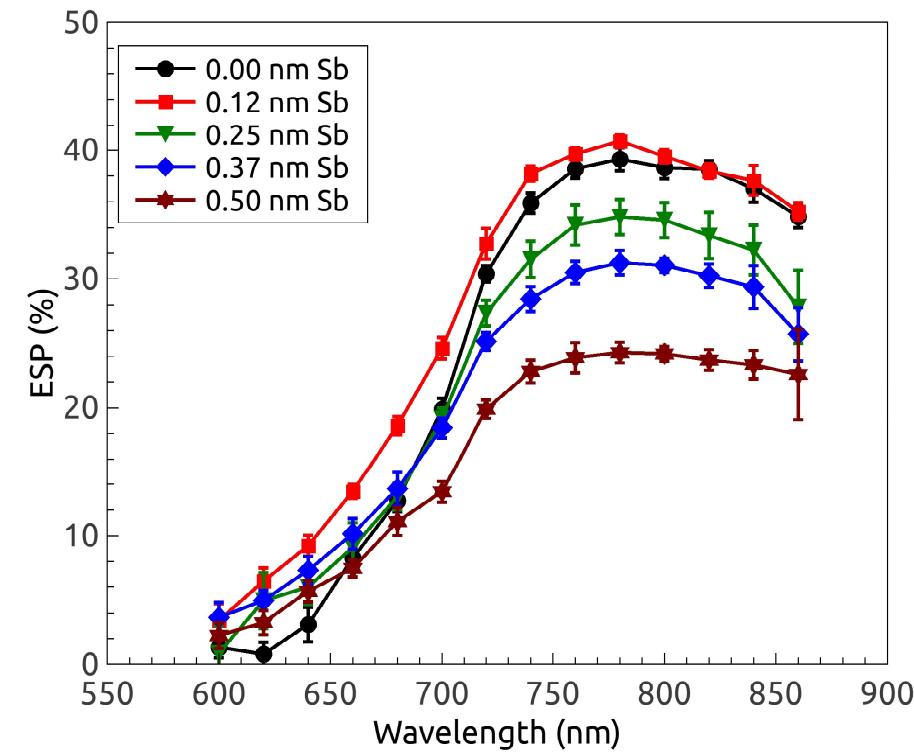
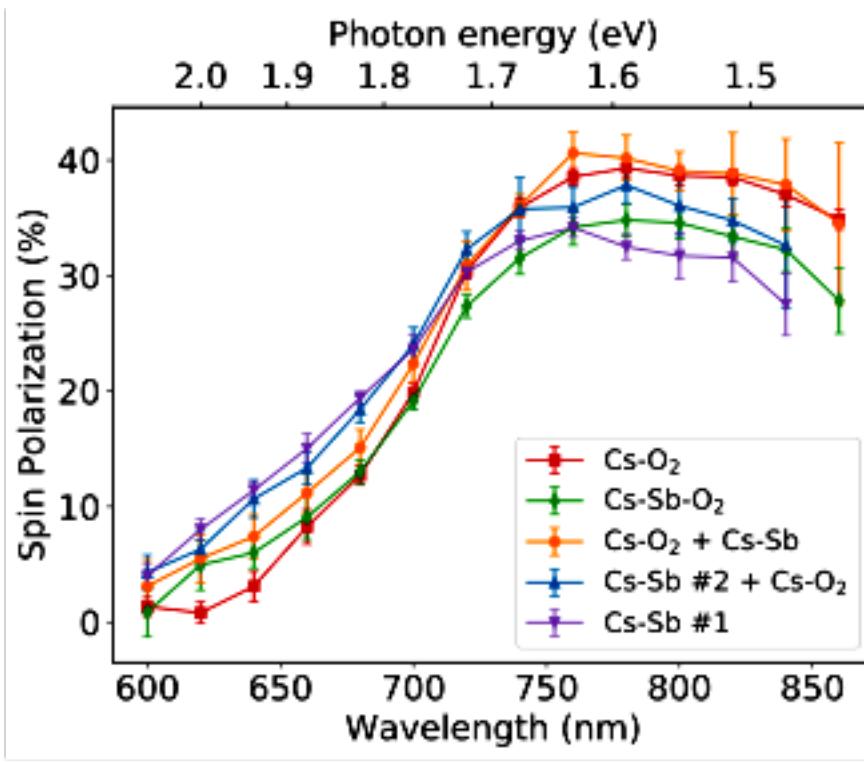
as we increase the layer thickness:

- QE decreases
- Lifetime increases



Spin polarization

J. Bae et al, NAPAC 2019, MOPLH17



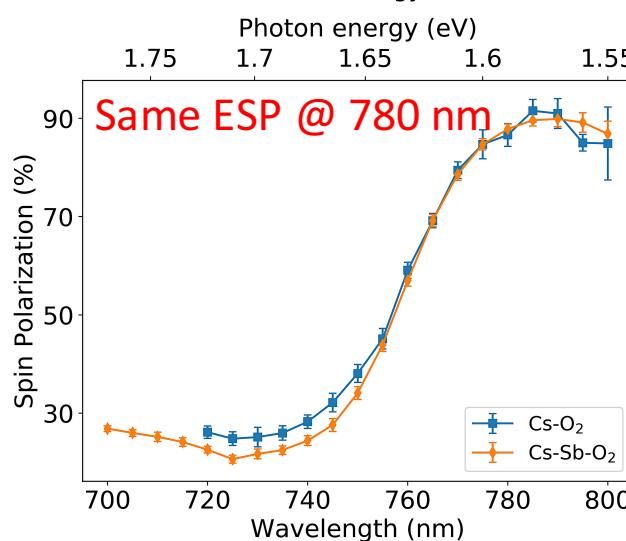
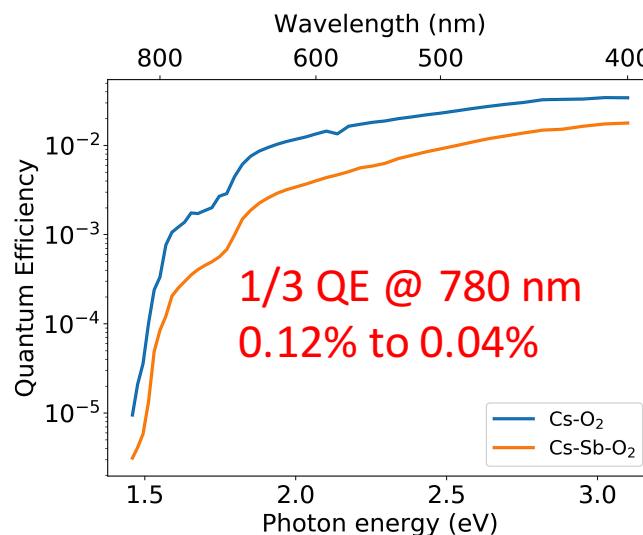
**Spin polarization is essentially preserved
(up to 1 nm thickness)**



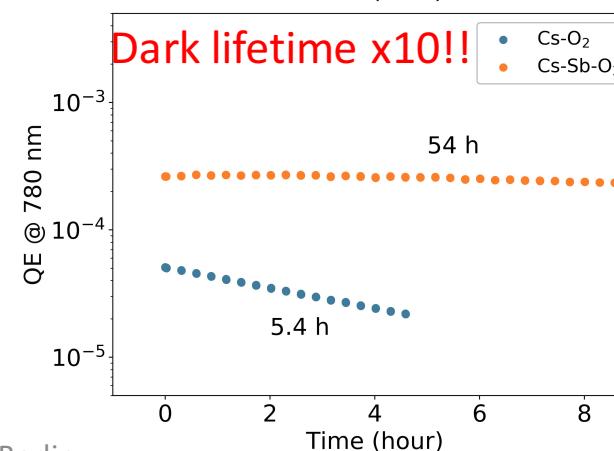
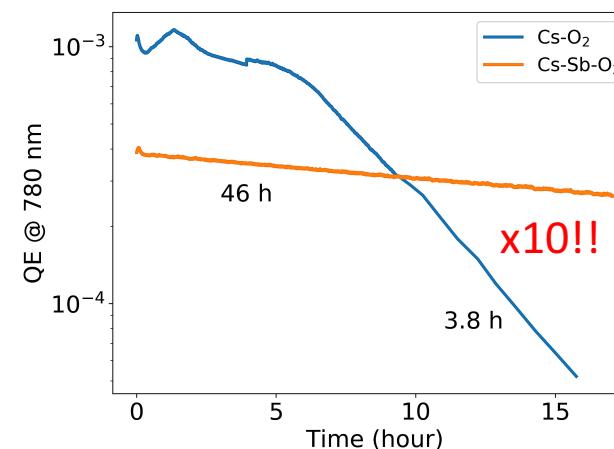
**Can all of this be
applied from bulk GaAs
to high polarization
photocathodes?**

YES!!

- Preliminary results!

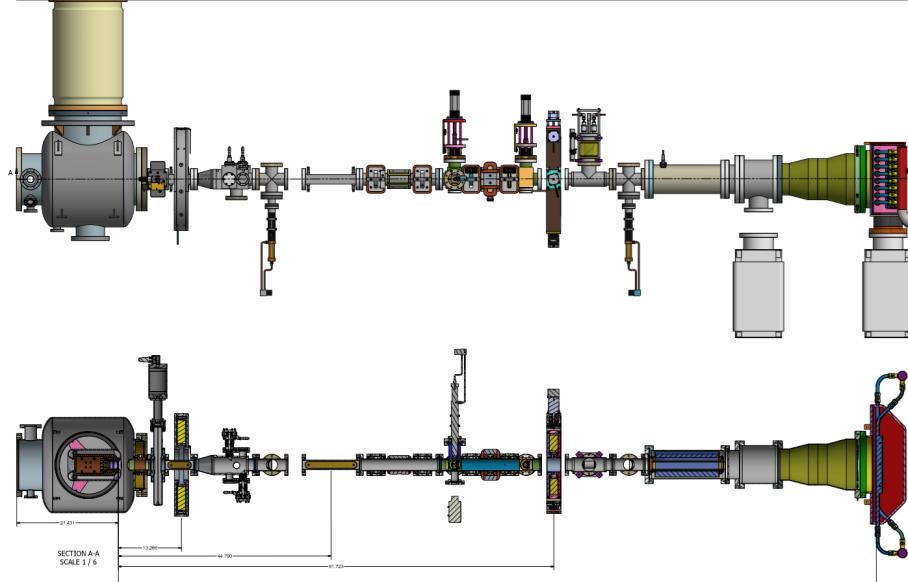
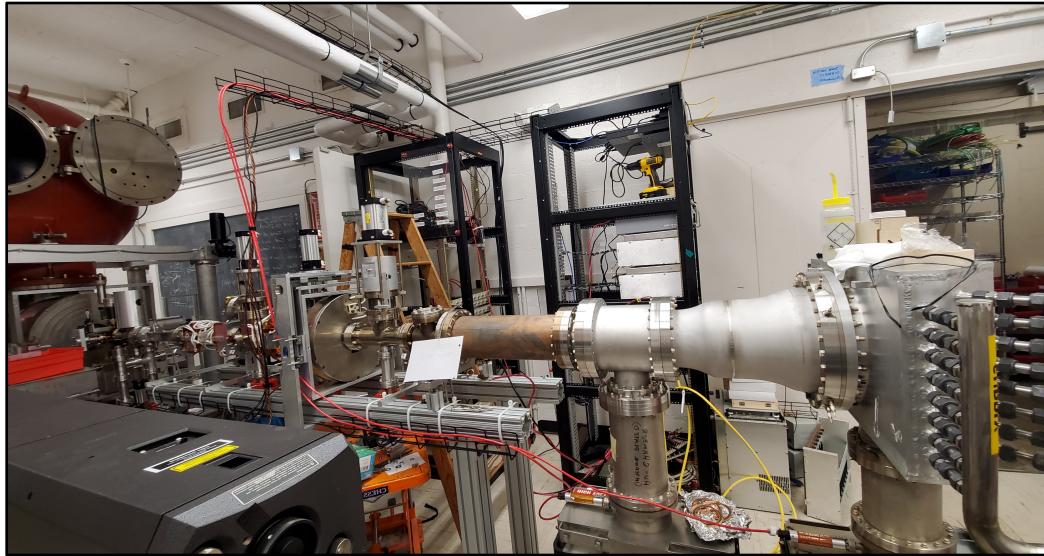


**SL GaAs/GaAsP non DBR
with P>80% @780nm
From Jlab injector group
Activated with 0.12 nm Sb**





Next?: High power cathode test



We are completing the installation of
a dedicated beamline:

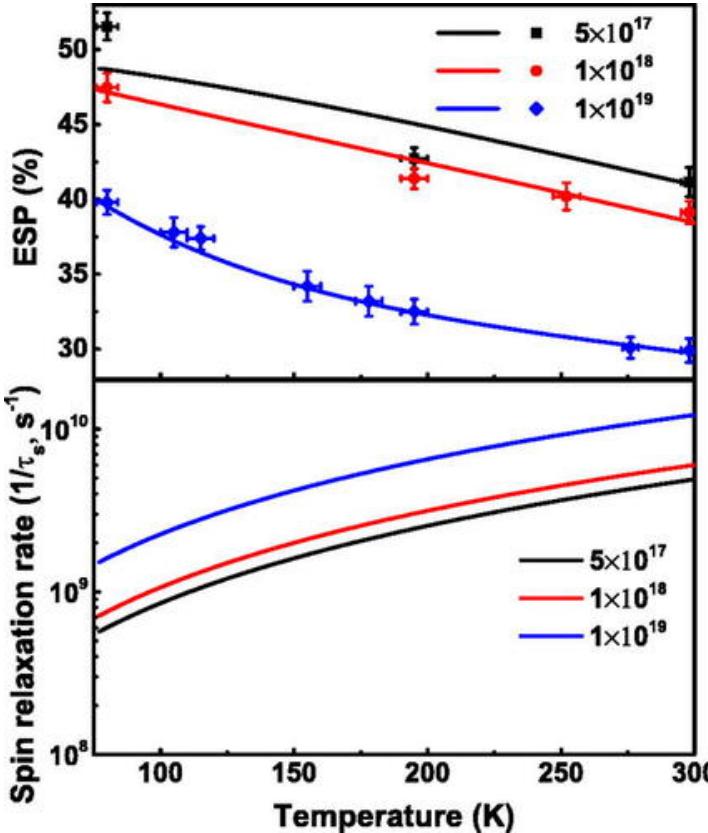
- Old CU-ERL gun 400kV @ 100 mA;
- Ion clearing electrodes;
- High power lasers;
- 75 kW beam dump;



ESP can be increased at low temperatures



REVIEW OF SCIENTIFIC INSTRUMENTS 89, 083303 (2018)



JOURNAL OF APPLIED PHYSICS 122, 035703 (2017)



A comprehensive evaluation of factors that influence the spin polarization of electrons emitted from bulk GaAs photocathodes

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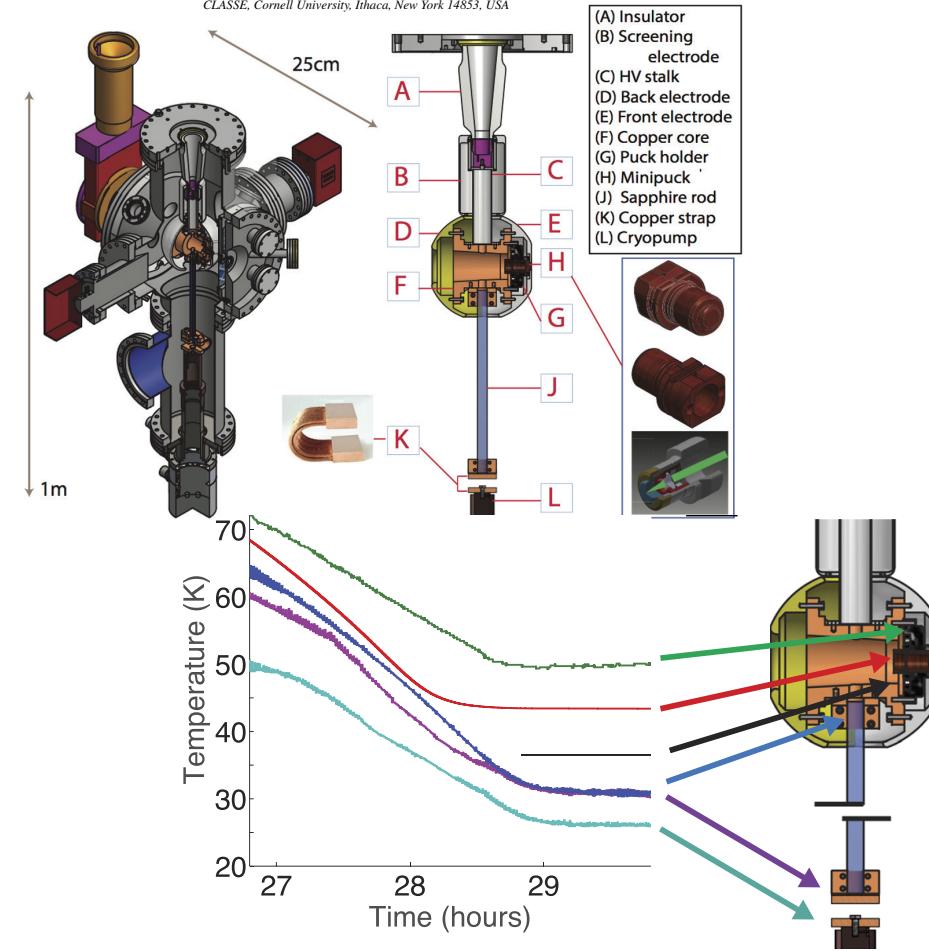
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A cryogenically cooled high voltage DC photoemission electron source

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Conclusions and outlook

- The use of alternative coatings to activate GaAs based photocathodes:
 - NEA can be achieved with either Cs-Te and Cs-Sb;
 - Lifetime is improved by a factor of 10x or more;
 - Polarization and QE are affected by thickness;
 - Trades off are required;
- Soon beam tests in a real gun;
- Cryogenic electron sources can be leveraged to increase polarization.
- kCoulomb from PES in sight?



Thank you for the attention!!

Acknowledgements to:

NP-DOE DE-SC0019122

NSF PHY-1549132

collaborators:

Ivan Bazarov, Jared Maxson

Alice Galdi, Jai Kwan Bae, Frank Ikponmwen

And the photocathode development group at CLASSE